

CHEMICALS AVAILABLE TO CLEAN ROOM USERS AS OF September 19, 2008

CHEMICAL NAME	CHEMICAL TYPE
1. Hydrobromic Acid 47-49%	Corrosive (Acid)
2. Aluminum Etchant Type A	Corrosive (Acid)
3. Chromium Etchant Type 1020	Corrosive (Acid)
4. Buffered Oxide Etch 5:1	Corrosive (Acid)
5. Buffered Oxide Etch 7:1	Corrosive (Acid)
6. Hydrofluoric Acid 49%	Corrosive (Acid)
7. Nitric Acid	Corrosive (Acid)
8. Hydrochloric Acid	Corrosive (Acid)
9. Acetic Acid	Corrosive (Acid)
10. Sulfuric Acid 96%	Corrosive (Acid)
11. Phosphoric Acid 85%	Corrosive (Acid)
1. Microposit CD-26 Developer	Corrosive (Base)
2. Microposit CD-30 Developer	Corrosive (Base)
3. Microposit MF-319 Developer	Corrosive (Base)
1. Methyl Alcohol (methanol)	Solvent
2. Acetone	Solvent
3. Isopropanol	Solvent
4. Trichloroethylene	Solvent
5. Baker BTS-220	Solvent
6. Baker PRS-3000	Solvent
7. Methyl iso-Butyl Ketone	Solvent
8. SU-8 50	Solvent
9. SU-8 2002	Solvent
10. SU-8 2005	Solvent
11. SU-8 2010	Solvent
12. SU-8 2015	Solvent
13. SU-8 2025	Solvent
14. SU-8 2100	Solvent
15. Omnicoat	Solvent
16. LOR 20B	Solvent
17. LOR 3A	Solvent
18. Remover PG	Solvent
19. MIBK/IPA 1:3 Developer	Solvent
20. SU-8 Developer	Solvent

September 2, 2008